

B. Specification

Please amend the paragraph at page 14, lines 5-14, as follows:

--wherein R₉ represents a substituent group on the aromatic ring, R₉ is selected from [[thg]] the group consisting of H, halogen, CN, NO₂, COOR₁₀, SO₂R₁₁ (wherein R₁₀ represents any one selected from the group consisting of H, Na, K, CH₃ and C₂H₅, and R₁₁ represents any one selected from the group consisting of OH, ONa, OK, halogen, OCH₃ and OC₂H₅), CH₃, C₂H₅, C₃H₇, (CH₃)₂-CH and (CH₃)₃-C, and in a case where there exist a plurality of units, R₉ may be different for each unit;--

Please amend the paragraph at page 15, lines 2-9, as follows:

--wherein R₁₂ is selected from [[thg]] the group consisting of H, halogen, CN, NO₂, COOR₁₃, SO₂R₁₄ (wherein R₁₃ represents any one selected from the group consisting of H, Na, K, CH₃ and C₂H₅, and R₁₄ represents any one selected from the group consisting of OH, ONa, OK, halogen, OCH₃ and OC₂H₅), CH₃, C₂H₅, C₃H₇, (CH₃)₂-CH and (CH₃)₃-C, and in a case where there exist a plurality of units, R₁₂ may be different for each unit; and--

Please amend the paragraph at page 25, lines 5-24, as follows:

--As microorganisms used for the production method of the present invention, any species of microorganisms may be used, as long as they have an ability to satisfy the above described conditions. Among them, microorganisms belonging to

Pseudomonas species are desirable. Specific examples of preferred species include Pseudomonas cichorii, Pseudomonas putida, Pseudomonas fluorescensfluorecens, Pseudomonas oleovorans, Pseudomonas aeruginosa, Pseudomonas stutzeri, and Pseudomonas jessenii. More specifically, examples of a suitable strain include Pseudomonas cichorii YN2 (FERM BP-7375), Pseudomonas cichorii H45 (FERM BP-7374), and Pseudomonas jessenii P161 (FERM BP-7376). These three types of strains were deposited on November 20, 2000 at the International Patent Organism Depository (IPOD) of National Institute of Advanced Industrial Science and Technology (AIST), Tsukuba Central 6, 1-1, Higashi 1-chome, Tsukuba-shi, Ibaraki-ken 305-8566, Japan, and they are described in U.S. Patent 6,586,562.--